

**RESPONSE UNDER 37. CFR 1.116  
EXPEDITED PROCEDURE  
EXAMINING GROUP 1752**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Hiroshi TAKANASHI et al.

Serial No. 09/262,077

Filed March 4, 1999



Docket No. 01497/FP/TOK-16-US/YH

Group Art Unit 1752

Examiner S. Lee

NEGATIVE-WORKING PHOTSENSITIVE  
RESIN COMPOSITION AND PHOTSENSITIVE  
RESIN PLATE USING THE SAME

THE COMMISSIONER IS AUTHORIZED  
TO CHARGE ANY DEFICIENCY IN THE  
FEE FOR THIS PAPER TO DEPOSIT  
ACCOUNT NO. 23-0975.

**PETITION FOR EXTENSION OF TIME**

Assistant Commissioner for Patents  
Washington, DC 20231

Sir:

Petition hereby is made for a two month extension of time to respond to the communication of  
January 3, 2000.

The fee of \$380.00 is

☒ submitted herewith.

☐ to be charged to Deposit Account No. 23-0975. A duplicate copy of this Petition is  
enclosed.

☐ Small entity status of this application is established by the verified statement under 37  
CFR 1.9 and 1.27 which

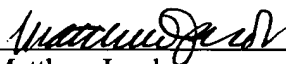
☐ is enclosed.

☐ has been previously submitted.

Respectfully submitted,

Hiroshi TAKANASHI et al.

By

  
Matthew Jacob

Registration No. 25,154  
Attorney for Applicants

MJ/pjm  
Washington, D.C.  
Telephone (202) 721-8200  
June 5, 2000

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